
Semiconductors, Metal Oxides, and Composites: Metallization and Electrodeposition of Thin Films and Nanostructures 2

Editors:

P. M. Vereecken

imec/KU Leuven
Leuven, Belgium

G. Oskam

Cinvestav-IPN
Mérida, Yucatán, Mexico

I. Shao

IBM T. J. Watson Research Center
Yorktown Heights, New York, USA

J. Fransaer

KU Leuven
Leuven, Belgium

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